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PATENT NUMBER and
ISSUE DATE

U.S. UTILITY Patent Application

APPL NUM 10038352	FILING DATE 01/02/2002	CLASS 438	SUBCLASS 577	GAU 2812	EXAMINER Aguayo, Ha
**APPLICANTS: Steiner Kurt; Vitkavage Susan; Lytle Steve; Gibson Gerald; Jessen Scott;					
**CONTINUING DATA VERIFIED: THIS APPLN CLAIMS BENEFIT OF 60/301,295 06/28/2001 +A					
** FOREIGN APPLICATIONS VERIFIED:					
PG-PUB <input type="checkbox"/> DO NOT PUBLISH <input type="checkbox"/>		RESCIND <input type="checkbox"/>			
Foreign priority claimed <input type="checkbox"/> yes <input type="checkbox"/> no		35 USC 119 conditions met <input type="checkbox"/> yes <input type="checkbox"/> no		ATTORNEY DOCKET NO 47071/MJM/A717	
Verified and Acknowledged Examiners's initials TITLE : Structure and method for isolating porous low-k dielectric films <small>U.S. DEPT. OF COMM./PAT. & TM.-PTO-436 (Rev. 12-94)</small>					

NOTICE OF ALLOWANCE MAILED		Assistant Examiner	CLAIMS ALLOWED	
			Total Claims	Print Claim for O.G.
ISSUE FEE		Primary Examiner	DRAWING	
Amount Due	Date Paid		Sheets Drwg.	Figs. Drwg.
<input type="checkbox"/> TERMINAL DISCLAIMER		PREPARED FOR ISSUE	Application Examiner	
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